600 Pixels MKID Superconductive Millimeter-wave Camera

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MKID (Microwave Kinetic Inductance Detector) group at Advanced Technology Center is developing superconductive camera in millimeter and submillimeter wavelengthes for LiteBIRD which detects CMB B-mode polarization and for Antarctica Dome Fuji telescope which observes distant galaxies with a wide field of view, in collaboration with KEK, Riken, Tsukuba University, Saitama University, and Okayama University. We developed 220 GHz 600 pixels imaging array in 2013 fiscal year [1,2].

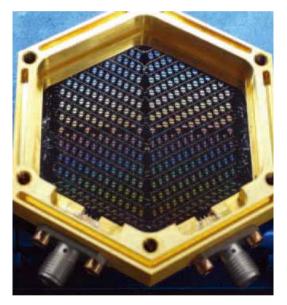


Figure 1: MKID 220 GHz - 600 pixels camera [1]. The size is around 6 cm.

MKID camera which is a new technology (P. Day et al. 2003) is a Cooper pair breaking detector. Superconducting resonators in MKID sense surface impedance variations owing to quasi-particles generate by incoming photons. The resonant frequencies distributed among 2–12 GHz are measured through a pair of coaxial cables with frequency comb generated by a DAC. The MKID is composed of a simple structure named CPW (co-planar waveguide), so a higher yield is expected.

To detect submillimeter-waves efficiently, the camera combined a lens array with superconducting planar antenna. Although silicon is an ideal material for millimeter-wave lens in the aspects of low loss and large refractive index, it was not available for this lens,



Figure 2: Si lens array and mixed epoxy anti-reflection layer (upper half). Slits reduce thermal stress of the Si and the AR [3].

because it was technically difficult to fabricate such Si lens array. ATC ME shop succeeded in fabricating millimeter-wave Si lens array by a milling process with a high-speed spindle and small diameter end-mills. We demonstrated symmetrical and low side-lobe beam pattern of this camera with the Si lens array. Two kinds of cryogenic epoxies were mixed to match the refractive index for Si and Alumina (Fig. 2) [3]. The AR thickness was controlled by machining with the same fabrication process as the Si lens array.

We also developed another AR of alumina using subwavelength structure (SWS). It is difficult to fabricate the SWS on small lens array, however, it is possible for the large lenses of the re-imaging optics. Among a few merits of SWS, this structure plays an important role as a low pass filter or an IR block filter.

T. Noguchi et al. studied excess noise of MKID generated by sub-gap states of superconducting [4]. A readout circuit with a complex FFT board has been also developed for 100 pixels MKID. The readout noise was evaluated to be as low as that of a single-channel readout system using an IQ mixer [5]. We are investigating a wide field optics for MKID camera.

References

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